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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Ilya Karpov et al.

Serial No.: 10/822,361

Filed: April 12, 2004

For: Fabricating Deeper and Shallower
Trenches in Semiconductor Structures

§ Art Unit: 2814
§
§ Examiner: Long Pham
§
§ Docket: ITL.0835D1US
§ P14730D
§
§ Assignee: Intel Corporation
§
§ Conf. No. 3077

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO PAPER NO. 04282006

Sir:

In response to the Office action mailed on May 2, 2006, please consider the following
amendments and remarks.

Date of Deposit: August 2, 2006
I hereby certify under 37 CFR 1.8(a) that this correspondence is
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Nancy Meshkoff